

<b>INFORMATION DISCLOSURE CITATION IN AN APPLICATION</b>  (Use several sheets if necessary)	Attorney Docket No.: <b>8060-1014</b>	Application No.: <b>10/520,633</b>
	Applicant: <b>Yuji TAKAKUWA</b>	
	Filing Date: <b>July 26, 2005</b>	Group Art Unit: <b>1792</b>

**U.S. PATENT DOCUMENTS**

Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing date (If appropriate)
	5,183,511	1993-02-02	YAMAZAKI et al.			

**FOREIGN PATENT DOCUMENTS**

Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation	
						Yes	No

**OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)**

	German Patent Office issued a German Office Action dated September 21, 2005, Application No. 10392913.4
	U.K. Patent Office issued a U.K. Office Action dated May 27, 2005, Application No. 0500273.8
	Diamond deposition technologies, Peter K. Bachmann and Willem van Enckeuort (1992) 1021-1034 Abstract

EXAMINER:  /Elizabeth Burkhart/	DATE CONSIDERED  06/05/2009
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.	

\* Abstract provided for the Examiner's convenience

ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /E.B./